

## Fabrication of high-efficiency dye-sensitized plastic photocells by low-temperature electrode preparation using a binder-free nanocrystalline TiO<sub>2</sub> coating paste

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Low-temperature preparation of mesoporous semiconductor electrodes for dye sensitization has been a subject of recent intense study for realizing full-plastic thin flexible photocells. We have devised high-efficiency plastic photocells by two approaches, electrophoretic deposition of TiO<sub>2</sub> nanocrystals<sup>1-3</sup> and preparation of binder-free viscous TiO<sub>2</sub> paste for doctor blade coating. Both methods need completion of inter-particle binding (necking) that enables efficient diffusion of conduction-band electrons through particles. In this paper binder-free pastes for doctor-blade coating were prepared by using TiO<sub>2</sub> precursor sol, which causes efficient chemical necking at temperatures below 200°C. We could achieve energy conversion efficiency of 4.6-5.4%, which is comparable with the top efficiency obtained by electrophoretic technique combined with post chemical treatments and with the efficiency obtained by high-temperature sintering of the same TiO<sub>2</sub> particle on a glass electrode.

Nanocrystalline TiO<sub>2</sub> (Showa Denko F-5, average size, 20 nm) was mixed with light-scattering large TiO<sub>2</sub> particle (G2, 500 nm) and acidic TiO<sub>2</sub> precursor sol in a mixture solvent of *tert*-butanol and ethanol to give a viscous paste free of binder materials. The viscosity of the paste was variable and was controlled by the composition of solvents. The paste (TiO<sub>2</sub> content, 14wt%) was coated on a transparent ITO-PET or ITO-PEN film (10-15 ohm/□) by the doctor blade method, dried, and heat-treated at 150-200°C for 5 min to form a mesoporous TiO<sub>2</sub> layer. TiO<sub>2</sub>-coated films showed high adhesion strength for TiO<sub>2</sub> layer (about 10 μm thick) against bending (see Fig. 1). The film electrode was dye-sensitized with a Ru complex (N719) and made into a thin cell (effective electrode area, 8 × 8 mm) with Pt-coated counterelectrode and methoxyacetonitrile-based I<sup>-</sup>/I<sub>3</sub><sup>-</sup> electrolyte composition.

Figure 2 shows I-V characteristics for the TiO<sub>2</sub> layer according to the present method and a reference layer prepared by high-temperature sintering at 550°C on glass electrodes. Photocurrent density ( $J_{sc}$ ) proved to reach the same level as that of sintered electrode. Open-circuit voltage ( $V_{oc}$ ) was lower than the sintered one suggesting that there is a wide distribution in conduction-band potential of TiO<sub>2</sub> layer as a result of low temperature preparation process. By optimization of the large particle (G2) content and thickness of TiO<sub>2</sub> layer, energy conversion efficiency under 100 mW/cm<sup>2</sup> reached around 4.6% at 11-12g TiO<sub>2</sub>/m<sup>2</sup> and G2 content of 30 wt%, as shown in Fig. 3. Non-volatile molten salt (imidazolium iodide) was also used as electrolyte, with which efficiency level was decreased to 3-3.5%. With this method, we are fabricating large-size full plastic photocells (>50 cm<sup>2</sup>) by introducing metal grid pattern electrodes on the ITO surface for current collection.



Fig. 1 Flexible plastic film photoelectrode bearing dye-sensitized mesoporous TiO<sub>2</sub> layer

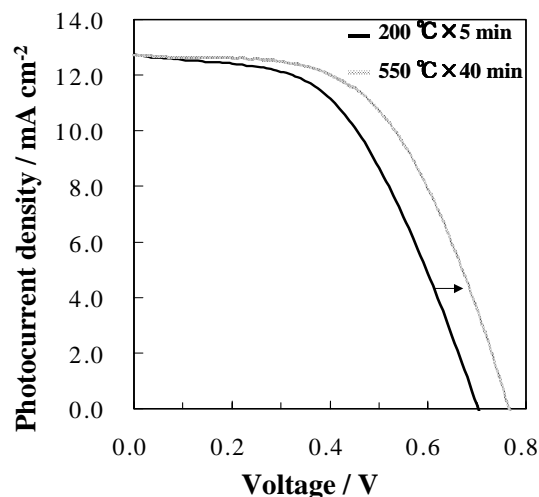


Fig. 2 Photocurrent-voltage characteristics of the low-temperature TiO<sub>2</sub> coating in comparison the same coating having been treated by high-temperature sintering at 550°C

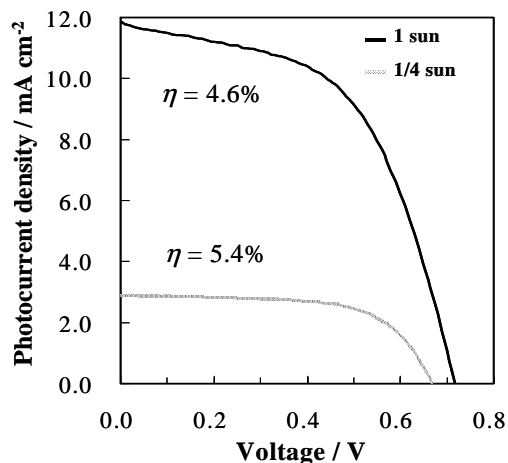


Fig. 3 Photocurrent-voltage characteristics of the low-temperature coated binder-free TiO<sub>2</sub> layer at incident intensities of 1 sun (100 mW/cm<sup>2</sup>) and 1/4 sun.

### References

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